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Conventional processing of semiconductor devices involves forming features in a silicon substrate. For example, the circuit devices may be formed by defining features such as gate electrodes in the substrate. Once the features have been formed, a transistor may be defined by gate structures and active regions in the substrate. Electrical connections may then be made to the source, drain, and back gates of the transistor using conductive contacts formed in one or more interlayer dielectric layers and electrically conductive structures formed in one or more of the dielectric layers. Features in the substrate may be formed using known masking and etching techniques. One such technique includes using a mask material such as photoresist on the substrate and patterning the mask material such that the desired pattern can be transferred to the substrate. Once the desired pattern has been transferred, the photoresist is removed and the substrate may be etched using the patterned mask as an etching mask. One common type of masking and etching involves defining active regions in a substrate, and defining contacts and gate structures on the active regions. Typically, the active regions and contacts are formed in a layer of material such as polysilicon. This layer may then be selectively etched by a known etching process such as a reactive-ion etching (RIE). After the RIE has been performed, the polysilicon may be removed, leaving the contacts and gate structures in the active regions. After the contacts and gate structures have been formed, a second layer of material may be formed over the substrate and the contacts and gate structures. As the second layer of material is formed, it will grow over the contacts and gate structures. The second layer of material may be planarized using an etch-back process in which the second layer of material and any mask material used to pattern the second layer of material are removed. The etch-back process may be performed using a RIE or a chemical-mechanical planarization (CMP) process. In a typical RIE process, one or more gas sources are used to etch the second layer of material. The gas sources may react with the various contaminants and/or gases in the chamber, and thereby remove the contaminants and gases from the RIE process. However, the 570a42141b

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